

*CLAIM AMENDMENTS*

1. (Currently Amended) A polybenzazole article superior in light resistance, which comprises a polybenzazole and a light-resisting agent that allows for a regular reflectance of the article of not more than 30% in not less than 30% of the wavelength region of from 450 nm to 700 nm, wherein the light-resisting agent is at least one member selected from the group consisting of *aniline*, *o-phenylenediamine*, *m-phenylenediamine*, *p-phenylenediamine*, *o-aminophenol*, *m-aminophenol*, *p-aminophenol*, 2-amino-4-nitrophenol, 2-aminophenol-4-sulfonamide, and 1,8-diaminonaphthalene.
2. (Original) The polybenzazole article of claim 1, wherein the light-resisting agent allows for a regular reflectance of the article of not more than 20% in not less than 10% of the wavelength region of from 450 nm to 700 nm.
3. (Original) The polybenzazole article of claim 1, which has a strength of not less than 35 g/d.
4. (Canceled)
5. (Canceled)
6. (Original) The polybenzazole article of claim 1, wherein the light-resisting agent is contained in a proportion of 0.01 to 20% by weight of the article.
7. (Canceled)
8. (Canceled)
9. (New) The polybenzazole article of claim 1, wherein the light-resisting agent comprises *m-phenylenediamine* and *p-phenylenediamine* in a weight ratio of about 1:1.
10. (New) The polybenzazole article of claim 1, wherein the light-resisting agent comprises *o-aminophenol* and *p-phenylenediamine* in a weight ratio of about 1:1.

11. (New) The polybenzazole article of claim 1, wherein the light-resisting agent comprises 2-amino-4-nitrophenol and *p*-phenylenediamine in a weight ratio of about 1:1.